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EXAMINER

IEVA, NICHOLAS

ART UNIT	PAPER NUMBER
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2836

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ELECTRONIC

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

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Office Action Summary	Application No. 10/591,945	Applicant(s) FUJISAWA ET AL.	
	Examiner NICHOLAS IEVA	Art Unit 2836	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 08 December 2008.
- 2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1,4,6-8,10,11 and 13-28 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1, 4, 6-8, 10, 11 and 13-2 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☒ The drawing(s) filed on 08 September 2006 is/are: a) ☒ accepted or b) ☐ objected to by the Examiner.
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some * c) ☐ None of:
1. ☐ Certified copies of the priority documents have been received.
 2. ☐ Certified copies of the priority documents have been received in Application No. _____.
 3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- | | |
|--|---|
| 1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892) | 4) <input type="checkbox"/> Interview Summary (PTO-413)
Paper No(s)/Mail Date. _____ |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948) | 5) <input type="checkbox"/> Notice of Informal Patent Application |
| 3) <input type="checkbox"/> Information Disclosure Statement(s) (PTO/SB/08)
Paper No(s)/Mail Date _____ | 6) <input type="checkbox"/> Other: _____ |

DETAILED ACTION

Response to the Amendments

1. Applicant's amendment to the claims filed on 07 November 2008 is acknowledged.

Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

3. **Claims 1, 26, and 27** are rejected under 35 U.S.C. 102(b) as being anticipated by **Benjamin et al. (US 6,563,076 B1)**.

Consider **claims 1, 26, and 27**, Benjamin et al. teaches a first electrode **216b** and a second electrode **216a**, said first electrode and said second electrode are applied voltages that are different in polarity (bipolar implementation) (are different from each other), generates at least an attracting performance by a gradient force (fringe field), and is capable of attracting a sample by allowing a surface of the insulating material to function as a sample attracting plane, wherein:

the insulating material **210** comprises an upper insulating layer (upper half of **217**), the first electrode **216b**, an inter-electrode insulating layer (the insulating layer between said first and second electrode), and the second electrode **216b**, and a lower insulating layer (lower half of **217**), which are laminated in the order of distance from the sample attracting plane; and

when the insulating material is viewed from a side cross-sectional view, the first electrode has a plurality of gaps, and the second electrode has a plurality of areas that are not overlapped with the first electrode (Benjamin; figure 2A, 1B and 1C; column 5, lines 35-62; column 2, line 46 – column 3, line 2).

Furthermore, the limitation “are by laminated in the order of distance from the sample attracting plane” is a product by process limitation, which means that this claimed limitation does not add any structure to the claimed invention.

(Even though Benjamin does not explicitly teach the limitation “are by laminated in the order of distance from the sample attracting plane”, Benjamin’s method would still achieve the same end result of having a insulating material that comprises an upper insulating layer, a first electrode, an inter-electrode insulating layer, and the second electrode, and a lower insulating layer)

Since Benjamin’s first electrode that is powered by a first power source of a first polarity would attract the sample, and Benjamin’s second electrode that is powered by a second power source of a different polarity would also attract the sample, it be inherent that a gradient force (fringe field) would be produced by the combination of the first and second electrodes that would attract the sample

by allowing the surface of the insulating material to function as a sample attracting plane. Also, the Applicant admits on page 14 of his arguments filed on 07 March 2008 that a bipolar arrangement of the electrodes would produce a gradient force.

Furthermore, the strength of the gradient force (fringe field) that would be produced will be controlled by a number of factors which includes the voltage applied to the first and second electrodes, the distance between the first and second electrodes, the size and shape of the electrodes, and the position/placement of the first and second electrodes. Furthermore, the strength of the gradient force (fringe field) is not claimed, what matters is that Benjamin teaches a bipolar electrostatic chuck that “generates at least an attracting performance by a gradient force.”

4. **Claim 27** is rejected under 35 U.S.C. 102(b) as being anticipated by **Shamouilian et al. (US 5,646,814)**, which was supplied in the applicant's information disclosure statement.

Consider **claim 27**, Shamouilian et al. discloses a bipolar electrostatic chuck which has a first electrode **24** and a second electrode **22** in an interior of an insulating material **26**, said first electrode connected to a first voltage source **48** and said second electrode connected to a second voltage source **46**, so as to generate at least an attracting performance by a gradient force (fringe field), and attracts a sample by allowing a surface of the insulating material to function as a sample attracting plane, wherein:

the insulating material **26** comprises an upper insulating layer **26c**, the first electrode **24**, an inter-electrode insulating layer **26b**, the second electrode **22**, and a lower insulating layer **26a** which are by laminated in the order of distance from the sample attracting plane; and

when the insulating material is viewed from a side cross-sectional view, the first electrode has a plurality of gaps, and the second electrode has a plurality of areas that are not overlapped with the first electrode (Shamoulian; figures 1 and 2b; column 2, line 54 - column 3, line 47; column 4, lines 34-62; column 3, line 56 – column 4, line 20; column 5, lines 60-67).

Since Shamoulian's first electrode **24** (unipolar or bipolar) that is powered by a first power source would attract the sample, and Shamoulian's second electrode **22** (unipolar or bipolar) that is powered by a second power source would also attract the sample, it be inherent that a gradient force (fringe field) would be produced by the combination of the first and second electrodes that would attract the sample by allowing the surface of the insulating material to function as a sample attracting plane.

Also, the strength of the gradient force (fringe field) that would be produced will be controlled by a number of factors which includes the voltage applied to the first and second electrodes, the distance between the first and second electrodes, the size and shape of the electrodes, and the position/placement of the first and second electrodes. Furthermore, the strength of the gradient force (fringe field) is not claimed, what matters is that

Shamouilian teaches a bipolar electrostatic chuck that “generates at least an attracting performance by a gradient force.”

Furthermore, Shamouilian et al. teaches that the size and shape of the first and second electrode can vary according to the size and shape of the chuck and the workpiece, in order to maximize the area that the electrodes have in contact with the workpiece and improve the clamping force applied to a workpiece (Shamouilian; column 5, lines 19-31).

Also, the Applicant admits on page 14 of his arguments filed on 07 March 2008 that a bipolar arrangement of the electrodes would produce a gradient force.

Claim Rejections - 35 USC § 103

5. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

6. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation

under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

7. **Claim 28** is rejected under 35 U.S.C. 103(a) as being unpatentable over **Benjamin et al. (US 6,563,076 B1)** in view of **Shufflebotham et al. (US 5,838,529)**.

Consider **claim 28**, Benjamin et al. discloses a bipolar electrostatic chuck above, but does not disclose that said bipolar electrostatic chuck is capable of attracting an insulating substrate.

Shufflebotham et al. teaches a bipolar electrostatic chuck that is capable of attracting an insulating substrate (Shufflebotham; claim 27).

Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to have incorporated the teachings of Shufflebotham into the bipolar electrostatic chuck taught by Benjamin et al., because Shufflebotham's teachings would have given one the ability to attract an insulating substrate.

8. **Claims 1, 4, 6, 11, 13, 15, 16, 20, and 21-23** are rejected under 35 U.S.C. 103(a) as being unpatentable over **Shamouilian et al. (US 5,646,814)**, which was supplied in the applicant's information disclosure statement, in view of **Benjamin et al. (US 6,563,076 B1)**.

Consider **claims 1 and 26**, Shamouilian et al. discloses a bipolar electrostatic chuck which has a first electrode **24** and a second electrode **22** in an

interior of an insulating material **26**, said first electrode connected to a first voltage source **48** and said second electrode connected to a second voltage source **46** generates at least an attracting performance by a gradient force, and attracts a sample by allowing a surface of the insulating material to function as a sample attracting plane, characterized in that:

the insulating material **26** comprises an upper insulating layer **26c**, the first electrode **24**, an inter-electrode insulating layer **26b**, the second electrode **22**, and a lower insulating layer **26a** which are by laminated in the order of distance from the sample attracting plane; and

when the insulating material is viewed from a side cross-sectional view, the first electrode has a plurality of gaps, and the second electrode has a plurality of areas that are not overlapped with the first electrode (Shamouilian; figures 1 and 2b; column 2, line 54 - column 3, line 47; column 4, lines 34-62; column 3, line 56 – column 4, line 20; column 5, lines 60-67).

However, Shamouilian does not clearly disclose that said first electrode and said second electrode are applied voltages that are different in polarity (are different from each other).

Benjamin et al. teaches a first electrode **216b** and a second electrode **216a**, said first electrode and said second electrode are applied voltages that are different in polarity (bipolar implementation) (are different from each other), generates at least an attracting performance by a gradient force (fringe field), and

is capable of attracting a sample by allowing a surface of the insulating material to function as a sample attracting plane, wherein:

the insulating material **210** comprises an upper insulating layer (upper half of **217**), the first electrode **216b**, an inter-electrode insulating layer (the insulating layer between said first and second electrode), and the second electrode **216b**, and a lower insulating layer (lower half of **217**), which are laminated in the order of distance from the sample attracting plane (Benjamin; figure 2A, 1B and 1C; column 5, lines 35-62; column 2, line 46 – column 3, line 2).

It would have been obvious to one of ordinary skill in the art at the time the invention was made to have incorporated the teachings of Benjamin et al. into the bipolar electrostatic chuck taught by Shamouilian et al., because Benjamin's teachings would provided an alternative means of connecting the first and second electrode that would have generated at least an attracting performance by a gradient force, and would have attracted a sample by allowing a surface of the insulating material to function as a sample attracting plane.

Consider **claim 4**, Shamouilian et al. and Benjamin et al. disclose a bipolar electrostatic chuck above.

Furthermore, Shamouilian et al. teaches that the first electrode is formed in a comb-like configuration (a series of first electrodes that when combined resembles a comb-like structure), and that the second electrode is formed in a comb-like configuration (a series of second electrodes that when combined resembles a comb like structure); when the insulating material is viewed from a

side cross-sectional view (Shamouilian; figure 2b; column 2, lines 54-61; column 4, lines 34-62; column 5, lines 19-59).

Also, Shamouilian et al. teaches that the size and shape of the first and second electrode can vary according to the size and shape of the chuck and the workpiece, in order to maximize the area that the electrodes have in contact with the workpiece and improve the clamping force applied to a workpiece (Shamouilian; column 5, lines 19-31).

However, Shamouilian and Benjamin et al. do not specifically that the second electrode is not overlapped with the first electrode, in a normal line direction of the sample attracting.

It would have been an obvious matter of design choice to have had the second electrode not overlapped with the first electrode, since such a modification would have involved a mere change in size of a component. A change in size is recognized as being within the level of ordinary skill in the art.

Consider **claim 6**, Shamouilian et al. teaches the first electrode is formed in a comb-like configuration (a series of first electrodes that when combined resembles a comb like structure, when the sample attracting plane is viewed from a side cross-sectional view); the second electrode is formed in a plane having a given planar area, when the sample attracting plane is viewed from a side cross-sectional view; and a part of the second electrode is overlapped with the first electrode in a normal line direction of the sample attracting plane

(Shamouilian; figure 2b; column 2, lines 54-61; column 4, lines 34-62; column 5, lines 19-59).

Consider **claims 11**, Benjamin et al. teaches that said first electrode **44** that centers on a circular portion having a given circular area, has a plurality of first annular portions that are concentrically disposed at a given interval, and has a first connection portion that connects the circular portion and the first annular portion portions to each other; and a second annular electrode **42** that has a width that is the same as the interval which is concentrically disposed (Benjamin; figure 1C; column 2, line 59 – column 3, line 2).

Furthermore, Shamouilian teaches a plurality of first and second electrodes and an inter-electrode isolating layer that would have electrically isolated the first and second electrodes from one another (figure 2b; column 5, lines 19-59).

Consider **claim 13**, Shamouilian et al. teaches that the distance between the first electrode **24** and the second electrode **22** is 1000 μm or equal to or more than 1 μm and equal to or less than 100 μm (Shamouilian; figure 2b; column 6, lines 16-29; claim 7; claim 43).

Consider **claim 15**, Shamouilian et al. teaches that the inter-electrode insulating layer **26b** is formed of a resin layer made of polyimide (Shamouilian; figure 2b; column 6, lines 47-53; column 5, lines 61-67; column 8, lines 16-61; column 9, lines 51-63).

Consider **claim 16**, Shamouilian et al. teaches that the resin layer is formed of one resin film (polyimide) (Shamouilian; figure 2b; column 6, lines 47-53; column 5, lines 61-67; column 8, lines 16-61; column 9, lines 51-63).

Consider **claim 20**, Shamouilian et al. teaches that a sectional configuration of a part or all of the first electrode **24** taken along the depth direction of the sample attracting plane comprises a configuration selected from the group consisting of a rectangle, a square and a circle (from this view the thin, flat, circular (disked shaped) first electrode can look like a rectangle or square) (Shamouilian; figure 2b; column 5, lines 19-31).

Consider **claim 21**, Shamouilian et al. teaches that a sectional configuration of a part or all of the second electrode **22** taken along the depth direction of the sample attracting plane comprises a configuration selected from the group consisting of a rectangle, a square and a circle (from this view the thin, flat, circular (disked shaped) second electrode can look like a rectangle or square) (Shamouilian; figure 2b; column 5, lines 19-31).

Consider **claim 22**, Shamouilian et al. teaches that that the inter-electrode insulating layer has a thickness of 100 micrometers **26b** (Shamouilian; figure 2b; column 6, lines 16-53-28).

Consider **claim 23**, Shamouilian et al. teaches that that the upper insulating layer has a thickness of 100 micrometers **26c** (Shamouilian; figure 2b; column 6, lines 16-53-28).

9. **Claims 7 and 8** are rejected under 35 U.S.C. 103(a) as being unpatentable over **Shamouilian et al. (US 5,646,814)**, which was supplied in the applicant's information disclosure statement, in view of **Benjamin et al. (US 6,563,076 B1)** and **Skill et al. (US 6,431,112 B1)**.

Consider **claims 7 and 8**, Shamouilian et al. and Benjamin et al. disclose a bipolar electrostatic chuck above, but they do not disclose the first electrode is formed in a lattice-like configuration.

In the same field of endeavor, electrostatic chucks, Skill et al. teaches a electrode that is formed in a lattice-like configuration (mesh configuration) having a plurality of openings each within a given area (Skill; column 7, lines 10-23).

Skill also mention that the mesh allows the insulating layer to be formed around the electrode in a strong physical interaction, thus the reducing the physical stress upon the insulating layer of the chuck during thermal cycling (Skill; column 7, lines 10-23).

Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to have incorporated the teachings of Skill et al. into the bipolar electrostatic chuck taught by Shamouilian et al. and Benjamin et al., because Skill's teachings would have reduced the physical stress an electrode puts upon the insulating layer of the chuck during thermal cycling.

Consider **claim 25**, Shamouilian et al., Benjamin et al. and Skill et al. disclose a bipolar electrostatic chuck above, but they do not disclose that the size of each of the openings (gaps) of the first electrode is in a range of 0.1 to 3.0 mm.

It would have been obvious to one having ordinary skill in the art at the time the invention was made to have to have had the size of each of the openings (gaps) of the first electrode in a range of 0.1 to 3.0 mm, Since it has been held that where the general conditions of a claim are disclosed in the prior art, discovering the optimum or working ranges involves only routine skill in the art. Furthermore, changing the size of the openings (gaps) of the first electrode would affect the electromagnetic field and the thermal properties of the overall electrostatic chuck.

10. **Claims 17 and 19** are rejected under 35 U.S.C. 103(a) as being unpatentable over **Shamouilian et al. (US 5,646,814)**, which was supplied in the applicant's information disclosure statement, in view of **Benjamin et al. (US 6,563,076 B1)** and **Ito (US Pub. 2003/0015521)**, which was supplied in the applicant's information disclosure statement.

Consider **claims 17**, Shamouilian et al. and Benjamin et al. disclose a bipolar electrostatic chuck above, but they do not disclose that the inter-electrode insulating layer is formed of a ceramic layer made of one or more elements selected from the group consisting of aluminum oxide, aluminum nitride, silicon carbide, silicon nitride, zirconia and titania.

In the same field of endeavor, electrostatic chucks (Ito; paragraph 0111-0113), Ito teaches an inter-electrode insulating layer that is formed of a ceramic layer made of one element selected from the group consisting of aluminum

oxide, aluminum nitride, silicon carbide, silicon nitride and zirconia (Ito; figures 1a and 1b; paragraph 0018, 0021-0024; 0039; 0111-0113).

It is well known that these materials have high thermal conductivity, good insulative properties, and can withstand high temperatures.

Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to have incorporated the teachings of Ito into the bipolar electrostatic chuck taught by Shamouilian et al. and Benjamin et al., because Ito's teachings would have increased the devices ability to withstand higher temperatures because these materials have a higher thermal conductivity.

Consider **claim 19**, Ito teaches an electrically conductive layer that is further formed on the surface of the insulating material; and the surface of the electrically conductive layer is capable of serving as the sample attracting plane (Ito; claim 18).

11. **Claims 17 and 18** are rejected under 35 U.S.C. 103(a) as being unpatentable over **Shamouilian et al. (US 5,646,814)**, which was supplied in the applicant's information disclosure statement, in view of **Benjamin et al. (US 6,563,076 B1)** and **Shufflebotham et al. (WO 97/23945)**, which was supplied in the applicant's information disclosure statement.

Consider **claims 17**, Shamouilian et al. and Benjamin et al. disclose a bipolar electrostatic chuck above, but they do not disclose that the inter-electrode insulating layer is formed of a ceramic layer made of one or more elements

selected from the group consisting of aluminum oxide, aluminum nitride, silicon carbide, silicon nitride, zirconia and titania.

In the same field of endeavor, electrostatic chucks, Shufflebotham et al. teaches an inter-electrode insulating layer that is formed of a ceramic layer made of silicon nitride (Shufflebotham; page 9, lines 5-14).

Shufflebotham also mentions that the use of a nitride as a preferred coating is selected because it gives the device an abrasion resistant surface which protects the electrodes, it has a high dielectric constant which improves the clamping force applied to the workpiece, and it has a high breakdown voltage (Shufflebotham; page 9, lines 7-14).

Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to have incorporated the teachings of Shufflebotham et al. into the bipolar electrostatic chuck taught by Shamouilian et al. and Benjamin et al., because Shufflebotham's teachings would have improved the clamping force applied to the workpiece.

Consider **claims 18**, Shufflebotham et al. teaches that the inter-electrode insulating layer is formed of silicon dioxide (Shufflebotham; page 9, lines 7-14).

12. **Claim 10** is rejected under 35 U.S.C. 103(a) as being unpatentable over **Shamouilian et al. (US 5,646,814)**, which was supplied in the applicant's information disclosure statement, in view of **Benjamin et al. (US 6,563,076 B1)** and **Yasushi (JP 2004-031594)**, which was supplied in the applicant's information disclosure statement.

Consider **claims 10**, Shamouilian et al. and Benjamin et al. disclose a bipolar electrostatic chuck above, but they do not disclose that the first electrode centers on a circular portion having a given circular area, has a plurality of first annular portion that are concentrically disposed at a given interval, and has a first connection portion that connects the circular portion and the first annular portions to each other; and the second electrode has a plurality of second annular portions having a width smaller than the interval which are concentrically disposed, is formed to have a second connection portion that connects the second annular portions to each other, the first annular portions and the second annular portions being alternately disposed in a normal line direction of the sample attracting plane.

In the same field of endeavor, electrostatic chucks, Yasushi teaches a first electrode **4a** that centers on a circular portion having a given circular area, has a plurality of first annular portion that are concentrically disposed at a given interval, and has a first connection portion that connects the circular portion and the first annular portions to each other; and a second electrode **4b** that has a plurality of second annular portions having a width smaller than the interval which are concentrically disposed, is formed to have a second connection portion that connects the second annular portions to each other (Yasushi; figure 2; paragraph 0016).

The size and shape of the first and second electrode can vary according to the size and shape of the chuck and the workpiece, in order to maximize the

area that the electrodes have in contact with the workpiece and improve the clamping force applied to a workpiece (Shamouilian; column 5, lines 19-31).

Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to have incorporated the teachings of Yasushi into the bipolar electrostatic chuck taught by Shamouilian et al. and Benjamin et al., because Yasushi's teachings would have improved the clamping force applied to a workpiece.

Furthermore, the court has held that it would have been obvious to substitute one known configuration for another in order to achieve the predictable results of maximizing the area that the electrodes have in contact with the workpiece and improving the clamping force applied to a workpiece.

13. **Claims 14 and 24** are rejected under 35 U.S.C. 103(a) as being unpatentable over **Shamouilian et al. (US 5,646,814)**, which was supplied in the applicant's information disclosure statement, in view of **Benjamin et al. (US 6,563,076 B1)** and **Kitabayashi et al. (US 6,768,627 B1)**.

Consider **claims 14 and 24**, Shamouilian et al. and Benjamin et al. disclose a bipolar electrostatic chuck above,

Furthermore, Shamouilian et al. teaches that the width of the inter-electrode gap (distance between the first and second electrode) is about 1 μm to about 0.1 mm or about 1 mm to about 100 mm and that the width of the first electrode is about 1 μm to about 0.1 mm (Shamouilian; figure 2b; column 6, lines 16-29; claim 7; claim 43).

However, they do not explicitly disclose that the width (z) of the first electrode and the width (z) of the inter-electrode gap (distance between the first and second electrode) are made equal to each other, and that z is in the range of 0.15 to .5 mm.

In the same field of endeavor, electrostatic chucks, Kitabayashi et al. teaches that when one is trying to electrostatically attract a glass substrate, one sets the width of the electrodes in the range of 0.5 to 1.0mm and the width (distance) between the electrode are in the range of 0.5 to 1.0 mm (Kitabayashi; figure 1; column 9, lines 32-43).

Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to have incorporated the teachings of Kitabayashi et al. into the bipolar electrostatic chuck taught by Shamouilian et al. and Benjamin et al., because Kitabayashi's teachings would have provided an alternative configuration of the widths of the electrodes and the interelectrode gap (distance between the first and second electrode) that would have been preferred when one wants to attract a glass substrate.

However, they do not explicitly disclose that the width (z) of the first electrode and the width (z) of the inter-electrode gap (distance between the first and second electrode) are made equal to each other.

It would have be obvious to one of ordinary skill in the art to have picked a value of 0.5 mm for the width (z) of the electrodes and for the width (distance) (z) between the electrodes, because this value would make the width (z) of the

electrodes and the width (z) between the electrodes equal to each other and have a width (z) in the range of 0.15 and 0.5 mm.

Also, it would have been obvious to one of ordinary skill in the art at the time the invention was made to have selected the overlapping portion of the range disclosed by the reference because overlapping ranges have been held to be a prima facie case of obviousness.

Response to Arguments

14. Applicant's arguments with respect to claims 28 regarding the newly add limitation of "the bipolar electrostatic chuck that is capable of attracting an insulating substrate" has been considered but are moot in view of the new ground(s) of rejection.

15. In response to applicant's arguments against the references individually, one cannot show nonobviousness by attacking references individually where the rejections are based on combinations of references.

16. Examiner respectfully disagrees with the Applicant that the combination of Shamoulilian and Benjamin does not teach generating at least an attracting performance by a gradient force, and attracts a sample by allowing a surface of the insulating material to function as a sample attracting plane.

Please refer back to the rejection of claims 1, 26 and 27 above.

In response to applicant's argument that the references fail to show certain features of applicant's invention, it is noted that the features upon which applicant relies (i.e., "are moved in cooperation with each other via the inter-electrode insulating layer")

are not recited in the rejected claim(s). Although the claims are interpreted in light of the specification, limitations from the specification are not read into the claims. See *In re Van Geuns*, 988 F.2d 1181, 26 USPQ2d 1057 (Fed. Cir. 1993).

Conclusion

17. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. **Horwitz et al. (US 5,103,367)** teaches electrodes formed circular configuration. **Naotoshi et al. (JP 2003-179128)**, which was supplied in the applicant's information disclosure statement, teaches electrodes formed in a band-like comb teeth configuration. **Katata et al. (US 6,500,686 B2)**, which was supplied in the applicant's information disclosure statement, teaches electrodes formed circular configuration and formed in a band-like comb teeth configuration. Both **Hausmann (US 6,104,596)** and **Herchen (US Pub. 2001/0046112 A1)** teach an electrode formed in a mesh (curb) configuration. Both **Masashi et al. (JP 08-064663)** and **Koichi (JP 11-251417)**, which both were supplied in the applicant's information disclosure statement, teach an electrically conductive layer that is formed on the surface of the insulating material. **Junji (JP 2003-318251)**, which was supplied in the applicant's information disclosure statement, teaches an insulating layer formed of silicon. **Masuda et al. (US 2002/0109955)**, which was supplied in the applicant's information disclosure statement, teaches a bipolar electrostatic chuck comprising a first electrode and a second electrode in an interior of an insulating material, said first electrode and second electrode being applied voltages that are different from each other.

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18. Any inquiry concerning this communication or earlier communications from the examiner should be directed to NICHOLAS IEVA whose telephone number is (571)270-1270. The examiner can normally be reached on M-TH (7:30am - 5pm), and F (7:30am - 4pm), EST.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Richard Elms can be reached on 571-273-1869. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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NI

/Stephen W Jackson/
Primary Examiner, Art Unit 2836